

EAST Search History**EAST Search History (Prior Art)**

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2	("20070164234").PN.	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/07/17 16:12
S1	954	(250/492.22).CCLS.	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/25 17:03
S2	9775	(250/492.1-492.3).CCLS.	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/25 17:04
S3	9775	(250/492.1-492.3).CCLS.	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/26 13:05
S4	86	S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4)	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:05
S5	36	S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:09

S6	33	S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam)	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:15
S7	24	S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity)	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:17
S8	9	S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4)	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:28

S9	9	@ad<"20050112" and S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4)	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:30
S10	0	@ad<"20050112" and S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibration with rais\$4 and vibration with low\$4	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:34
S11	0	@ad<"20050112" and S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:34

		\$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with rais\$4 and vibrat\$4 with low\$4				
S12	1	@ad<"20050112" and S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with (rais\$4 or low\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:35
S13	1	@ad<"20050112" and S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with (rais\$4 or low\$4) and liquid	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:38

S14	0	@ad<"20050112" and S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with (rais\$4 or low\$4) and liquid and ("3" or three) with degree \$4 with freedom	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:54
S15	1	@ad<"20050112" and S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and liquid same (optical with (column or body))	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 15:18
S16	0	@ad<"20050112" and S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and liquid with liquid with (optical with (column))	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:28
S17	0	@ad<"20050112" and S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and liquid with (optical with (column))	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:29

S18	0	@ad<"20050112" and S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and liquid with (optical with (column or body))	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:30
S19	1	@ad<"20050112" and S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and dry with immersion	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:31
S20	4	@ad<"20050112" and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and dry with immersion	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:32
S21	4	@ad<"20050112" and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and liquid with (column)	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:33
S22	0	@ad<"20050112" and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and liquid with (optical with column)	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:33

S23	1	@ad<"20050112" and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and liquid with (optical with (body or column))	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:33
S24	0	@ad<"20050112" and S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with (rais\$4 or low\$4) and abnormal\$4	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:42
S25	1	@ad<"20050112" and S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with (rais\$4 or low\$4) and situation	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:43

S26	1	@ad<"20050112" and S3 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with (rais\$4 or low\$4) and (situation or problem\$4 or abnormalit \$4 or issue)	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:47
S27	22	@ad<"20050112" and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with (rais\$4 or low\$4) and (situation or problem\$4 or abnormalit \$4 or issue)	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:48

S28	0	@ad<"20050112" and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with (rais\$4 or low\$4) and (situation or problem\$4 or abnormalit \$4 or issue) and earthquake	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:50
S29	1	@ad<"20050112" and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and earthquake	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:50
S30	1	(US-20070146663-\$).did.	US_PGPUB	ADJ	ON	2008/03/26 18:44
S31	1	(US-6654095-\$).did.	USPAT	ADJ	ON	2008/03/26 18:51
S32	5	S12 or S13 or S15 or S19 or S23 or S25 or S26 or S29 or S30 or S31	US_PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 18:54

EAST Search History (Interference)

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